



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: )  
)  
Masahiro SHIRATORI et al. ) Confirmation No.: 2482  
)  
Application No.: 10/777,213 ) Group Art Unit: 1763  
)  
Filed: February 13, 2004 ) Examiner: Allan W. Olsen  
)  
For: ETCHING MASK )

Commissioner for Patents  
U.S. Patent and Trademark Office  
Alexandria, VA 22314

Sir:

**RESPONSE TO RESTRICTION REQUIREMENT**

In response to the Restriction Requirement dated March 17, 2006, the period for response to which extends through April 17, 2006, Applicants hereby elect the invention identified in the Office Action as "Group I, Claims 1-6."

Applicants respectfully request formal examination of this application.

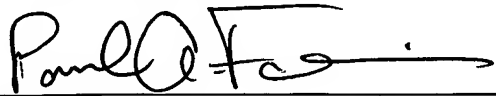
Applicants respectfully assert that no fee is due in connection with the filing of this response. However, if there are any fees due in connection with the filing of this response, please charge those fees to Deposit Account No. 50-0573.

Respectfully submitted,

**DRINKER BIDDLE & REATH LLP**

Dated: April 13, 2006

By:

  
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